

<p align="center"><b>NATIONAL PHASE UTILITY APPLICATION</b></p> <p align="center"><b>Transmittal to the (DO/EO/US) Under 35 USC 371</b></p>	<p>Attorney Docket No.: SHIGA7.036APC  First Named Inventor: Yasuo Masuda  Int'l Application No.: PCT/JP2004/010270  Int'l Filing Date: July 13, 2004  Priority Date Claimed: July 16, 2003  Title: POSITIVE PHOTORESIST COMPOSITION AND  METHOD OF FORMING RESIST PATTERN  Express Mail Label No.: EV718232865US</p>
<p><b>Direct all correspondence to Customer No.: 20995</b></p> <p align="right">Date: January 12, 2006 Page 1 of 3</p>	

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The following enclosures are transmitted herewith to be filed in the patent application of:

**Inventors:**

1. Yasuo Masuda
2. Toshiki Okui

**APPLICATION ELEMENTS:**

- (X) This is a FIRST submission of items concerning a filing under 35 U.S.C. § 371.
- (X) A copy of the International Application as filed (35 U.S.C. § 371(c)(2)) has been communicated by the International Bureau.
  - (X) PCT/IB/308 enclosed.
- (X) An English translation of the International Application as filed is attached hereto.
- (X) Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. § 371(c)(3)) have not been and will not be made.
- (X) An Oath or Declaration signed by the inventors (35 U.S.C. § 371(c)(4)).

**OTHER APPLICATION PARTS:**

- (X) Preliminary Amendment in 5 pages.
- (X) Recordation form cover sheet and Assignment in 3 total pages (cover sheet & assignment).
- (X) An Information Disclosure Statement and PTO/SB/08 equivalent listing references for consideration:
  - (X) Listing 15 references.
  - (X) Enclosing 10 references.
- (X) Cover page of PCT publication WO 2005/007719 A3.
- (X) International Search Report and Written Opinion.
- (X) Application Data Sheet in 2 pages.

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Date: January 12, 2006  
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**FILING FEES:**

FEE CALCULATION				
FEE TYPE & DETERMINATION		LARGE FEE	CALCULATION	TOTAL
Basic Filing Fee under 1.492(a)		1631 (\$300)		\$300
Search Fee under 1.492(b) (enter one in TOTAL column)				
(1)	USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)	1640 (\$0)		\$400
(2)	USPTO was the ISA (noncompliant claims)	1641 (\$100)		
(3)	Foreign Search Report Enclosed	1642 (\$400)		
(4)	No Search Report Enclosed	1632 (\$500)		
Examination Fee under 1.492(c) (enter one in TOTAL column)				
(1)	USPTO was ISA/IPEA & claims satisfy Art. 33 (1)-(4)	1643 (\$0)		\$200
(2)	Non US IPEA or Noncompliant Claims	1633 (\$200)		
Excess Claims	5 - 20 = 0	1615 (\$50)	0 x 50 =	\$0
Excess Ind. Claims	1 - 3 = 0	1614 (\$200)	0 x 200 =	\$0
Multiple Dep. Claim		1616 (\$360)		\$0
Application Size Fee	0 - 100 = 0	1681 (\$250)	0 x 250 =	\$0
Late English Translation		1618 (\$130)		
Assignment		8021 (\$40)	1 x 40 =	\$40
			<b>TOTAL FEE DUE</b>	<b>\$940</b>
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The Commissioner is hereby authorized to charge any additional fees which may be required, now or in the future, or credit any overpayment to Account No. 11-1410.



Daniel E. Altman  
Registration No. 34,115  
Attorney of Record  
Customer No. 20,995  
(949) 760-0404

# Knobbe Martens Olson & Bear LLP

Intellectual Property Law

2040 Main Street  
 Fourteenth Floor  
 Irvine, CA 92614  
 Tel 949-760-0404  
 Fax 949-760-9502  
 www.kmob.com

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Daniel E. Altman

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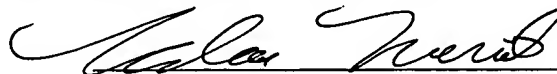
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Attorney Docket No. : SHIGA7.036APC  
 Applicant(s) : Masuda et al.  
 For : POSITIVE PHOTORESIST COMPOSITION  
 AND METHOD OF FORMING RESIST  
 PATTERN  
 Attorney : Daniel E. Altman  
 "Express Mail" Label No. : EV718232865US **EV718232865US**  
 Date of Deposit : January 12, 2006

I hereby certify that the accompanying

Transmittal letter; English translation of specification in 49 pages; 1 sheet of drawings; Preliminary Amendment in 5 pages; Application Data Sheet in 2 pages; signed Declaration and Power of Attorney in 2 pages; Recordation Form Cover Sheet and Assignment in 3 pages; International Search Report and Written Opinion; PCT/IB/308; cover page of PCT publication WO 2005/007719 A3; Information Disclosure Statement, PTO Form PTO/SB/08 Equivalent with 10 references; Check for Filing Fee; Return Prepaid Postcard

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